

Form PTO 1449 U.S. Dept of Commerce
Rev 7-80 Patent & Trademark Off.

Atty. Docket No. : Serial No.

STL9-2000-0055US1:09/613,083

Applicant(s)

John Ehrman

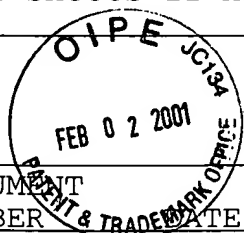
File Date

Group

July 10, 2000

2751 2178

LIST OF PRIOR ART CITED BY APPLICANT(S)
(Use several sheets if necessary)



U.S. PATENT DOCUMENTS

EXAM.:	DOCUMENT	CLASS/	FILING
INTL.:	NUMBER	SUBCLASS	DATE
CBP:AA:	5440482	08/08/95 Davis	707/16 03/25/93
CBP:AB:	5485373	01/16/96 Davis et al.	715/536 03/25/93
CBP:AC:	5758314	05/26/98 McKenna	704/8 05/21/96
CBP:AD:	5787452	07/28/98 McKenna	707/536 05/21/96
CBP:AE:	5793381	08/11/98 Edberg et al.	345/467 09/13/95
CBP:AF:	5832507	11/03/98 Harper et al.	707/200 04/01/96
CBP:AG:	5873111	02/16/99 Edberg	707/536 05/10/96
			715

FOREIGN COUNTRIES

DOC. NO.	DATE	COUNTRY	CLASS/	TRANSLATION
			SUBCLASS	YES : NO
BA:EPO852037	01/12/99	EP	G06F 17/22	X
BB:WO 97/10556	20/03/97	PCT	G06F 17/22	X
CBP:BC:JP10260884	09/29/98	Japan	G06F 12/00	Abstract only

OTHER PRIOR ART (INCLUDE. AUTHOR, TITLE, DATE, PERTINENT PG., ETC.)

CA: "National Language Support Reference Manual" IBM National Language
: : Design Guide Volume 2, 4th Edition, August 1994.

CB: "National Language Support Bidi Guide", IBM National Language
: : Design Guide Volume 3, 1st Edition, October 1995.

CC: "Language Reference" IBM High Level Assembler for MVS® & VM & VSE,
: : Release 3, 3rd Edition, September 1998.

CD: "Programmer's Guide", IBM High Level Assembler for MVS® & VM
: : & VSE, Release 3, 3rd Edition, September 1998.

CE: "National Language Support" IBM AS/400e series, Version 4,
: : 2nd Edition, February 1998.

CF: "The Unicode Standard Version 3.0", The Unicode Consortium.
: : 2nd Printing, April 2000.

CG: "Designing Internationalized Products" IBM National Language
: : Design Guide, 4th Edition, October 1996.

EXAMINER

DATE CONSIDERED

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant (s).